Mitigation of radon background by surface coating for the next generation of liquid xenon dark matter detectors **INSTITUT UPHYSIK**



ELBERG

Giovanni Volta, Florian Jörg, Hardy Simgen Max-Planck-Institut für Kernphysik, Heidelberg **Technology and Instrumentation in Future Liquid Noble Gas Detectors** Kobayashi-Maskawa Institute, Nagoya

Radon background in rare event searches

- Rn-induce background are of great importance in many rare-event searches (e.g., dark matter)
- Radon atoms are found naturally in the environment and in detector components as part of U/Th decay chains.
- Radon progeny radioactive decay within the energy range of WIMP searches hampers detector sensitivity (e.g., β decay of ²¹⁴Pb, daughter of ²²²Rn)

238

228Th

1.91 y

Its reduction requires a well-planned radon mitigation strategy lacksquare

a

4.08 MeV

232TI



Prevention Removal

Rn-induce

background

I M K M



Radon requirement for future Xe-based detectors

A next-generation liquid xenon observatory for dark matter and neutrino physics, Aalbers, J. and others

- DARWIN/XLZD (\geq 40 t active LXe volume) aims for ×10 reduction in the radon content to probe WIMPnucleon cross sections down to a few 10⁻⁴⁹ cm^{2 [1]}
- The current technology and the volume dilution is not enough to reach \sim 0.1 μ Bq/kg



Largest background reduction challenge:

- . Aggressive ²²²Rn assay campaign previous detector construction
- Improvement of current purification techniques
- 3. Prevention of Rn emanation into the target

Surface coating: novel mitigation strategy

IDEA - Reduce the radon released from a material by a thin coating layer which seals its surface



REQUIREMENTS

- Thick enough to contain the radon recoil (O(10 nm) for $E_{recoil}^{222_{Rn}} = 86.2 \ keV$, $E_{recoil}^{220_{Rn}} = 103.4 \ keV$)
- Sufficiently tight to prevent radon diffusion
- Must feature a high degree of radio purity, especially regarding ²²⁶Ra

03/15

Investigated techniques

Radon reduction factor R was investigated for several techniques using thoriated welding rods

• $R = \frac{A_{before}}{A_{after}}$, where A is ²²⁰Rn (²²²Rn) the activity measured using electrostatic radon monitor (proportional counters)

	a the second sec	
A	and the state of the	and the second
and the second	and the second s	1
a to a stand of		and the second
Sarris Co. Bly		and I light
1 2000	Constants Provide Statements	12
	Contraction of the local data	
and the state		
Charles and		and the second
	CONTRACTOR AND A CONTRACTOR OF A DESCRIPTION OF A DESCRIPANTE A DESCRIPANTE A DESCRIPANTE A DESCRIPTION OF A	
1		
the state of the state		
a state and		
1 1 2 2 2		10 · · · · · ·
Service and		12 3010
22. 5. 6 1		and the
3 B. S		* 12 Mar 1
24 2 20		200000
22 5 20		a the start
A total the		a the second
2 miles to		1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1 1
Sel and		1 1 1
1. 1 ml.		S 12 52
No. 1 State State		1 4 5 Te
1995 - 18 C		and the second s
The state of the second	and the second second second	the state
No Carto In all	THE OWNER AND ADDRESS OF TAXABLE PARTY.	and the second
Con Providence		a martine
the state of		\$1
and the get		-
Carter Carton		A Party and a second
BUSIES STOR		a the second
1. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1. 1		1 200 10 2
13 2 12		a start of the
and the state		1 - 1 - 1
The state of the state		1
a - 4 - 2 20	A REAL PROPERTY AND A REAL	A Carton
and the second		1
Contraction of the second		1 3.6. 2
· ····································		122 . 3ª
No lite The	and the second s	A CAR
the states		the t
the state		1
NY TA MATTER		and the second
the for the second		Martin Contra
The start of the	WIG-Elektroden	A State State
City Contrato	THO LICKHOUCH	and the second second
and the state of	IIG-Electrodes	A BARRISSING
and the second second	in Anlehnung an / manufactured acc. to:	No. Contraction
and the second se	ISO 6848:2004	
and the state		the star
	Ø 1,0 x 175 mm	· · · · · ·
	Ø 1,0 x 175 mm	
	Ø 1,0 x 175 mm	
	Ø 1,0 x 175 mm Los-Nr.: / Lot-no.: 86801	
	Ø 1,0 x 175 mm Los-Nr.: / Lot-no.: 86801 Inhait / Content:	
	Ø 1,0 x 175 mm Los-Nr.: / Lot-no.: 86801 Inhalt / Content: 10 Stück / pcs	
	Ø 1,0 x 175 mm Los-Nr.: / Lot-no.: 86801 Inhalt / Content: 10 Stück / pcs	
	Ø 1,0 x 175 mm Los-Nr.: / Lot-no.: 86801 Inhait / Content: 10 Stück / pcs	
	Ø 1,0 x 175 mm Los-Nr.: / Lot-no.: 86801 Inhait / Content: 10 Stuck / pcs	
	Ø 1,0 x 175 mm Los-Nr.: / Lot-no: 86801 Inhalt / Content: 10 Stuck / pcs	
	Ø 1,0 x 175 mm Los-Nr: / Lot-no: 86801 Inhait / Content: 10 Stuck / pcs	
	Ø 1,0 x 175 mm Los-Nr. / Lot-no. 86801 Inhalt / Content. 10 Stuck / pcs UOUFRAM INDUSTRIE TRAUNSTEIN Mode is Generary	
	Ø 1,0 x 175 mm Los-Nr: / Lot-no: 86801 Inhait / Content: 10 Stuck / pcs UOLFRAM INDUSTRIE TRAUNSTEIN Mode in Generary www.enders.eduate.com	
	Ø 1,0 x 175 mm Los-Nr: / Lot-no: 86801 Inhait / Content: 10 Stück / pcs UOLFRAM INDUSTRIE TRAUNSTEIN Mode in Generary www.wolfram. industrie con	

Mathad	Coating Material	Thickness [µm]	Reduction	
Methou			²²⁰ Rn	²²² Rn
Sputtering	Titanium	0.4 - 0.8	4.5	~ 2.1
Plasma spraying	Copper	3	22	//
Epoxy resin	Stycast	≈ 200	≥ 74	//
Chemical Vapor deposition	Diamon like carbon	1	3	~ 1.4
Electrochemical plating	Copper	5	150	~ 7.4

Giovanni Volta, 16 Feb 2024

I M K M

LANCK-INSTITUT Kernphysik Ieidelberg



Electrochemical plating (EPC) of copper

- ECP of copper performed with a local setup at MPIK laboratory
- Motivated literature results on radiopure electro-formed copper
- Electrolyte: 0.05 mol/l CuSO₄ + 1 mol/l H₂SO₄
- Solution heated to ~45°C and continuously stirred

Reduction at the metal workpiece:

$$Cu^{2+}_{(aq)} + 2e^- \rightarrow Cu_{(s)}$$

Best results obtained (for 5 µm layer) with 50 mA/cm² $\xrightarrow{1 \ \mu m}$ 10 mA/cm²





Giovanni Volta, 16 Feb 2024

Validation with ²²⁴Ra implanted samples

- Reproducibility of ECP procedure on stainless stell^[1] verified using *homemade* ²²⁴Ra recoil implanted stainless steel samples $A_{implanted} = O(10Bq)$
- Rather superficial implantation and widely spread
- Challenging due to the short half-life of ²²⁴Ra ($T_{1/2} \approx 3.6$ days)











 $[1] 2 \text{ cm} \times 2 \text{ cm} \times 1 \text{ cm}$

K M

Giovanni Volta, 16 Feb 2024

²²⁰Rn emanation measurements

- Three individual radon emanation measurements (~ one week each): before coating, after coating, after decoating
- The ²²⁰Rn emanation rate estimated based on the detected ²¹²Po activity, accounting for the full decay chain (e.g., Bateman equation)





I M K M

²¹²Po activity evolution



Giovanni Volta, 16 Feb 2024



²¹²Po activity evolution





Test on ²²⁶Ra implanted sample

- Two stainless steel^{[1] 222}Rn sources produced at ISOLDE facility in 2017 via implantation of ²²⁶Ra
- \sim 8 Bq implanted in 1 cm x 1 cm area at the center, with mean depth of 7.9 nm with a σ_{std} of 2.3 nm
- Unexpected large ²²²Rn reduction factor!





Giovanni Volta, 16 Feb 2024

Short term goals:

- Verify ISOLDE ²²²Rn reduction
- Investigate deeply coating morphology
- Scale up ECP setup
- Characterize further ECP procedure



New ISOLDE implantation campaign

- New ²²⁶Ra implantation campaign performed last November
- Not only stainless steel but also other metals (copper, titanium, lead) as well as insulators (PTFE, acrylic, glass) and semiconductors (germanium and silicon)
- 30 keV ²²⁶Ra ion beams guided into 2 cm × 2 cm samples hosted in vacuum chamber



Available radon sources

- Eleven new radon source with up to ~4 Bq of ²²⁶Ra activity (verified w/ in-situ γ -spectroscopy)
- Sample arrived in February 2024 at MPIK: full characterization started (e.g., α and γ spectroscopy, and Rn emanation measurements)

Sample	²²⁶ Ra ions implanted [×10 ¹¹]	²²⁶ Ra expected activity [Bq]	
SS #11	1.5	2.05	
Ti #04	3.0	4.1	
SS #10	0.03	0.04	
Cu #02	3.5	4.8	
SS #01	3.0	4.1	
SS #02	3.0	4.1	
PTFE #01	0.26	0.36	
Ti #01	3.1	4.2	
SS #07	2.2	3.02	
SS #08	//	//	
Pb #01	0.15	0.2	



K M



- First ECP test with hollow stainless-steel cylinders
- Good mechanical adhesion obtained in all tests (e.g, survived tape test)
- Main limitation: current power supply (Delta Elektronika SM1540-D, I_{max}=40 A) and bulky setup





- First ECP test with hollow stainless-steel cylinders
- Good mechanical adhesion obtained in all tests (e.g, survived tape test)
- Main limitation: current power supply (Delta Elektronika SM1540-D, I_{max}=40 A) and bulky setup





- First ECP test with hollow stainless-steel cylinders
- Good mechanical adhesion obtained in all tests (e.g, survived tape test)
- Main limitation: current power supply (Delta Elektronika SM1540-D, I_{max}=40 A) and bulky setup





- First ECP test with hollow stainless-steel cylinders
- Good mechanical adhesion obtained in all tests (e.g, survived tape test)
- Main limitation: current power supply (Delta Elektronika SM1540-D, I_{max}=40 A) and bulky setup







New ECP setup

- New setup in construction at MPIK: ~15-liter double-walled HDPE vessel
- New power supply (EA-PS 8080-510) with current (voltage) output up to 510 A (80 V)
- Perform coating of vessel-like geometry up to 1 m²

Ultimate goal is to electroplate a radon emanation vessel





Radio purity of the coating layer evaluation

- ²²²Rn emanation measurements w/ and w/o coating to assert the radio purity of the layer
- Measured performed with proportional counter setup at MPIK
- No evidence of additional Radium: UL at 90% of the Ra introduced is $80 \mu Bq/m^2$







Summary

- Surface coating is a promising technology for Radon background reduction in future dark matter detector
- EPC showed the best reduction results
- New sources available for radon emanation studies
- Proved the scaling up of the setup to reasonable geometries

... what next?

- Characterization of new radon sources and validation of previous reduction results
- Commissioning of new coating setup and coating of vessel-like geometry
- Investigate further coating morphology and EPC procedure











Thank you for the attention!

BACK-UP SLIDES

Radon background in XENONnT

- 222 Rn is dominant electronic recoil background in XENONnT (A $_{222Rn} \sim 1 \mu Bq/kg$ in SR0)
- Radon emanation measurements indicate a various sources distributed over entire experimental infrastructure



²²²Rn emanation [mBq]

KM

-PLANCK-INSTITU JR KERNPHYSIK HEIDELBERG



Radon detector at MPIK



MPIK ²²²Rn infrastructure:

- >20 ultralow background miniaturized proportional counters
- Sensitivity: ~10 atoms.
- 8 parallel counting lines.
- Fully automated ²²²Rn concentration system (AutoEma).
- ~15 sample vessels(0.1 -80 lit.).
- 3 electro-static ²²²Rn monitors.





Radon emanation reduction factor

- Performed Ge spectroscopy of the electrolyte after coating and decoating: monitor ²⁰⁸Tl γ line
- True reduction factor $\in [R_{lower}, R_{upper}] \rightarrow 50 \le R \le 250$!



KM

LANCK-INSTITU Kernphysik (eidelberg

Coating morphology

Secondary Electron Microscopy (SEM) investigation of coating

Rough surface with spherical structures





